

**Research Infrastructure  
of RRC “Kurchatov  
Institute” for works in  
Nanotechnology and  
Materials Science Area**

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# The main directions of investigation

- Creation of functional nanoelements for various purpose including for memory, sensor controls, keys, transistors etc.
- Creation of nanomaterials for various purpose, including: fullerenes, nanotubes, nuclear power materials etc.
- Creation of Micro Electromechanical (MEMS) and Nano Electromechanical (NEMS) Systems.
- Works in a scope of nanotechnology for needs of medicine and biology.
- Creation of a new manufacturing techniques for functional nanoelements and nanodevices production.
- Creation of a new manufacturing techniques for nanomaterials production.



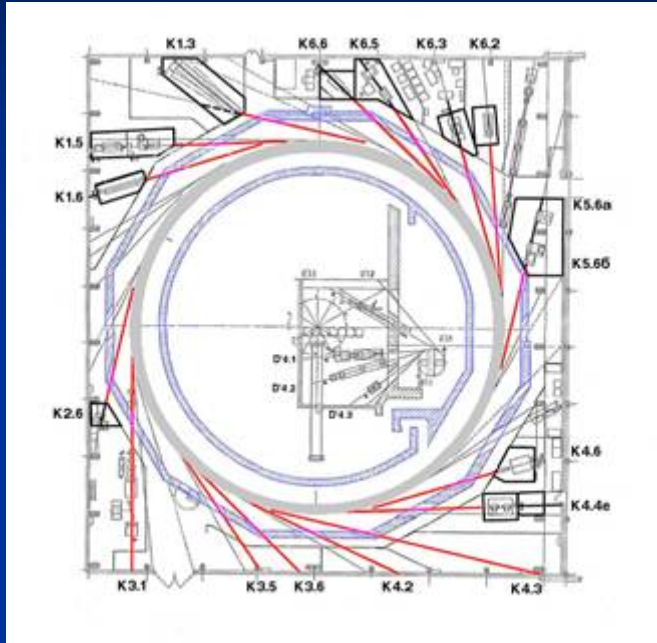
# Kurchatov Synchrotron Radiation Source



The Kurchatov Synchrotron Radiation (SR) Source is the first dedicated SR facility in Russia for the production and use of synchrotron radiation. The combination of specific properties of synchrotron radiation like high flux, collimation and polarization, temporal structure and a wide wavelength range from infrared to the hard X-rays makes the source a powerful tool for the research in physics, chemistry, biology, materials science and micro and nanotechnology.



# Kurchatov Synchrotron Radiation Source



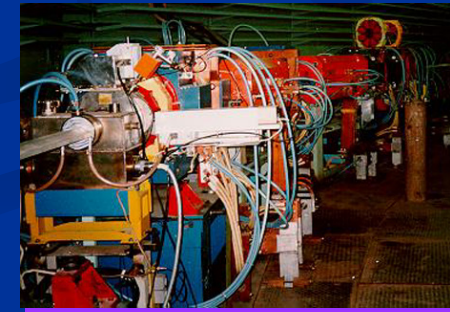
**Linear accelerator  
(injector)**      **Large storage ring  
(X-rays)**



**Small storage ring  
(booster, VUV)**



**Control room**



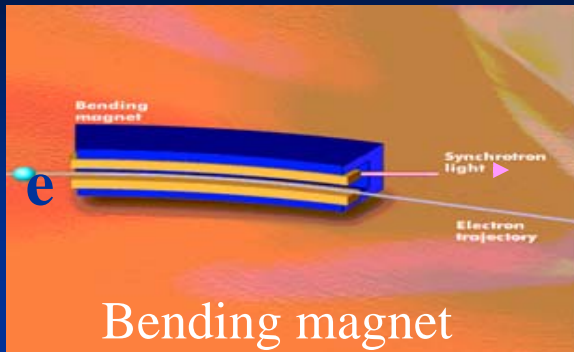
## «Siberia-2»



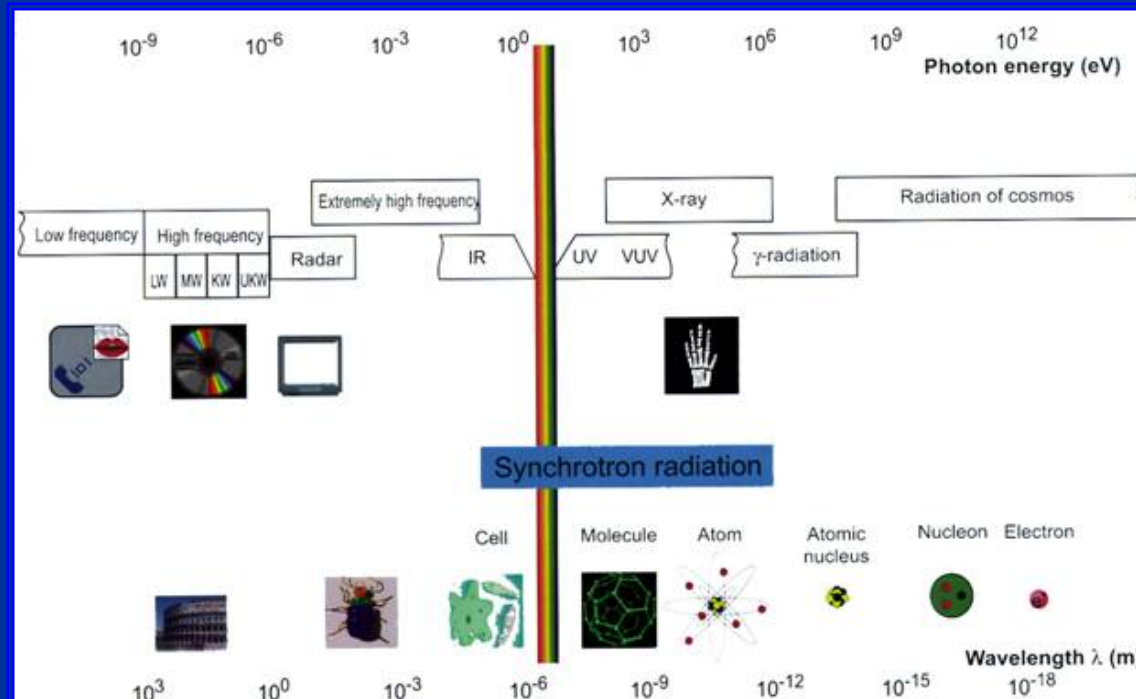
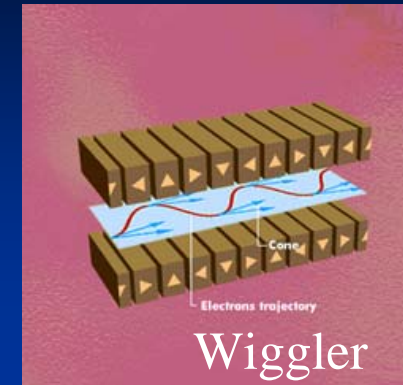
Large storage ring «Siberia-2» is a source of X-ray radiation



# Synchrotron radiation: generation and properties



- Wide spectral range
- High brilliance
- Polarization
- Time structure
- Natural collimation
- Ultra high vacuum



The source provides the synchrotron radiation (SR) in the wavelength range extending from 0.1 to 2000 Å.

# Experimental stations

## X-ray stations

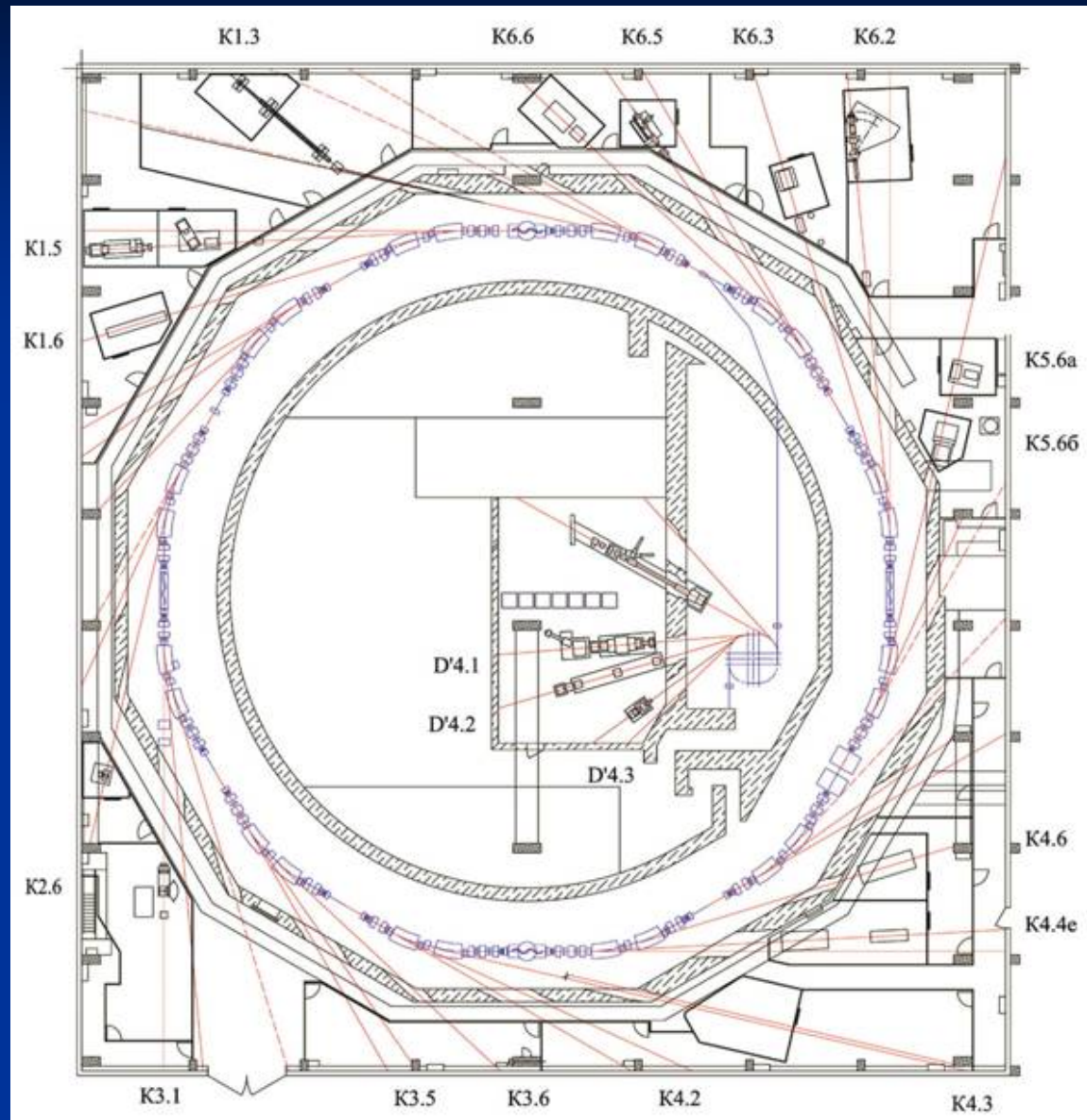
- |    |  |
|----|--|
| 1  | Protein Crystallography                    |
| 2  | Precise X-ray Optics                       |
| 3  | X-ray Crystallography and Material Science |
| 4  | Medical and Industrial Diagnostics         |
| 5  | LIGA                                       |
| 6  | EXAFS                                      |
| 7  | Small Angle Scattering                     |
| 8  | Time-Resolved Small-Angle Diffraction      |
| 9  | Refraction optics                          |
| 10 | Diffraction topography and tomography      |

## VUV stations

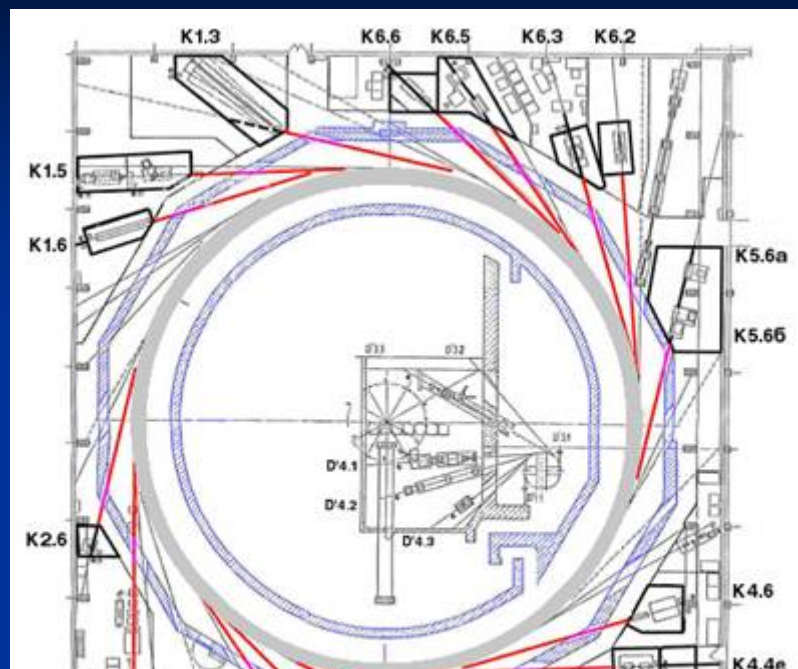
- |    |                                       |
|----|---------------------------------------|
| 11 | Photoelectron Spectroscopy            |
| 12 | Optical Investigations of Dielectrics |
| 13 | VUV Luminescence and Absorption       |

## X-ray stations under construction

- |    |   |
|----|---|
| 14 | X-ray Structure Analysis                        |
| 16 | Surface Investigations (Molecular Beam Epitaxy) |
| 17 | Organic films (Lengmure-Blodgett)               |
| 18 | Photon-Nuclear Reactions                        |
| 19 | High Pressure                                   |



# EXPERIMENTAL STATIONS



## Precise X-ray optics

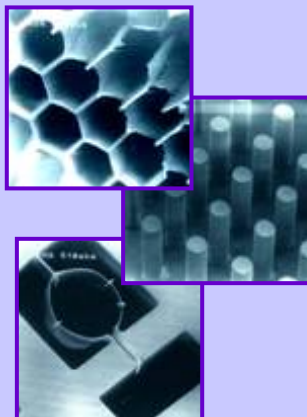
K 6.6



ω-20

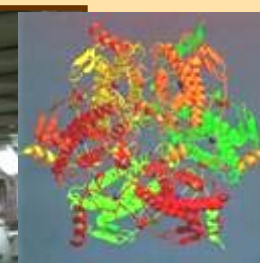
## Deep X-ray lithography

K 6.3



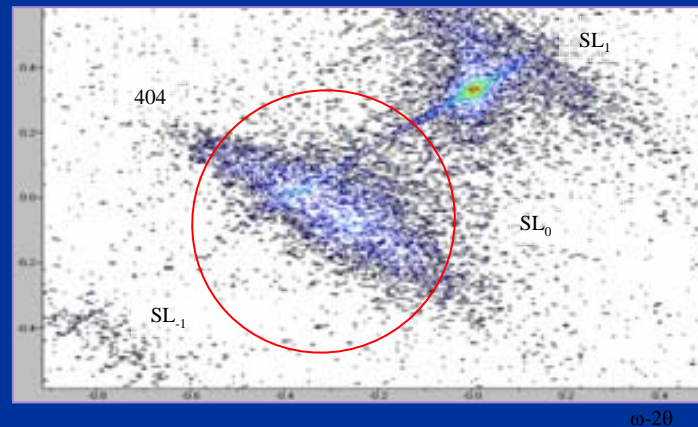
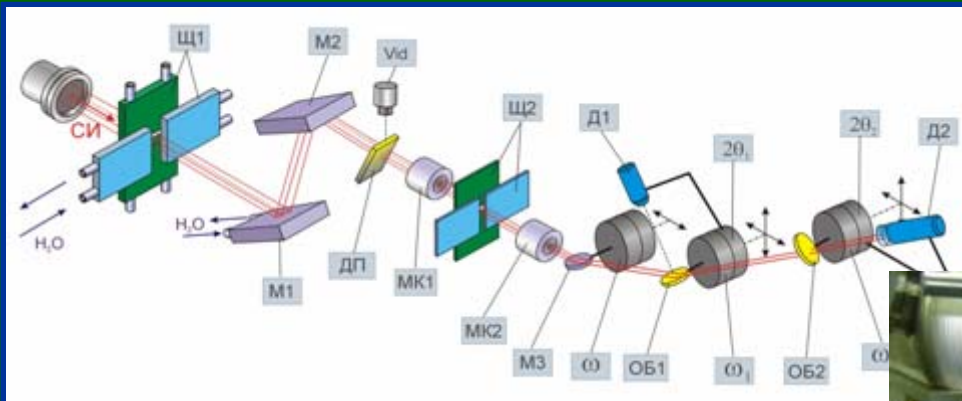
## Protein crystallography

K 4.4 e





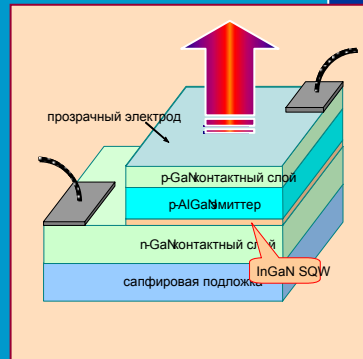
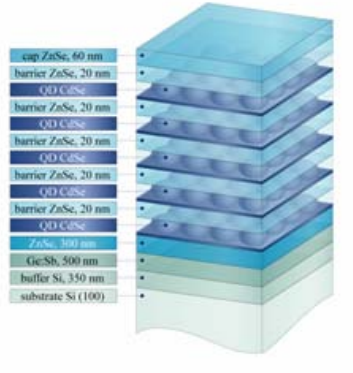
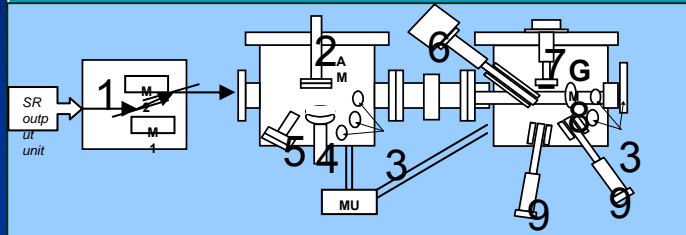
# Station for Material Science and Crystallography



Diffuse scattering at quantum dots nanostructure in InAs/GaAs

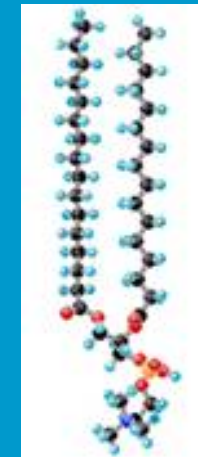
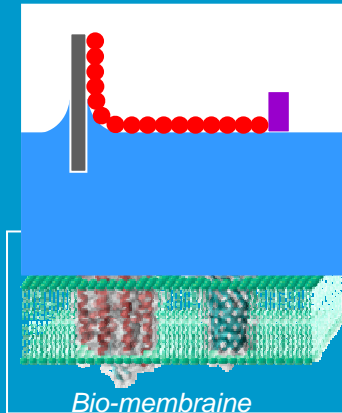
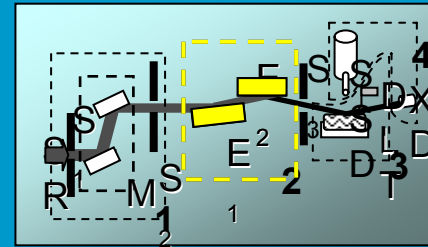
# Stations for Nanotechnology and Nanodiagnostics

## Molecular Beam Epitaxy



## Heterostructure

## Lengmur-Blodgett technology



A special interest is given to the experimental stations for synthesis or structure diagnostics of organic and inorganic nanomaterials (nanotechnology).

# Station for Molecular Beam Epitaxy





# Neutron center on Reserch Reactor IR-8



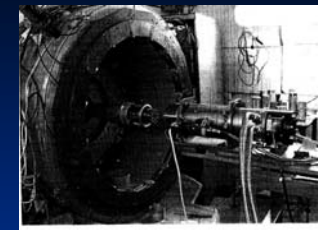
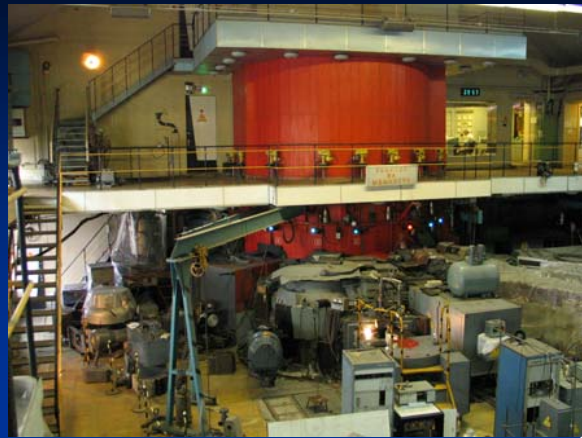
ATOS



MOND



DISK



MEN



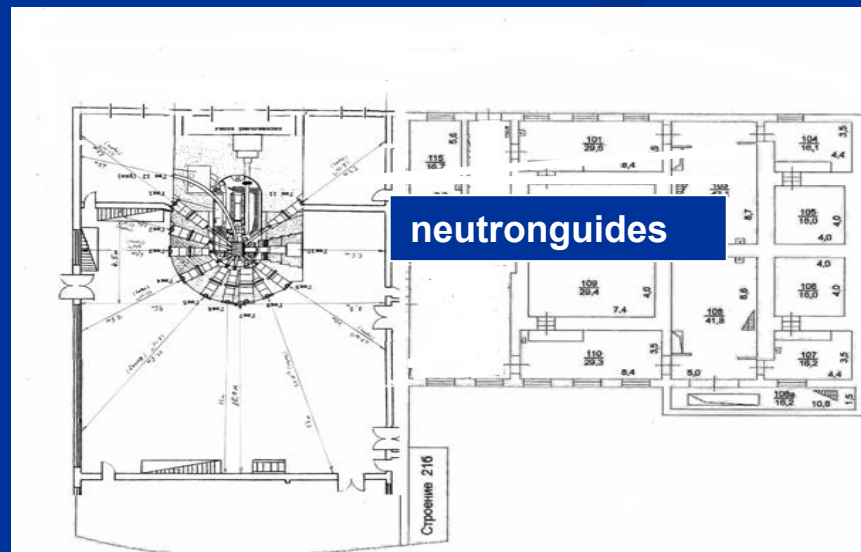
STOIK

Inelastic scattering  
Neutron diffraction  
Small angle scattering  
Neutron optics



Capillary  
microbeam  $\sim 500 \mu$

New instruments:  
Reflectometer SANS,  
High fields,  
High pressure,  
Very cold neutrons



# Neutron diagnostics of amorphous and nanoscale materials

## Problems:

Structure, dynamics,  
phase transitions  
in nanoscale systems

Behaviour of nanosystems  
in a wide range temperatures,  
pressure and doses  
of an irradiation

Properties nanosystems:  
thermostability  
sorptional  
mechanical  
magnetic

## Systems:

Metal  
Carbon  
Hydrocarbonic  
Metal - hydrogen  
Photon crystals



Neutron diffractometer DISK



high pressure cell

## Methods

receptions and researches

reactor irradiation  
mechano-activation  
melt spinning  
hydrogenization



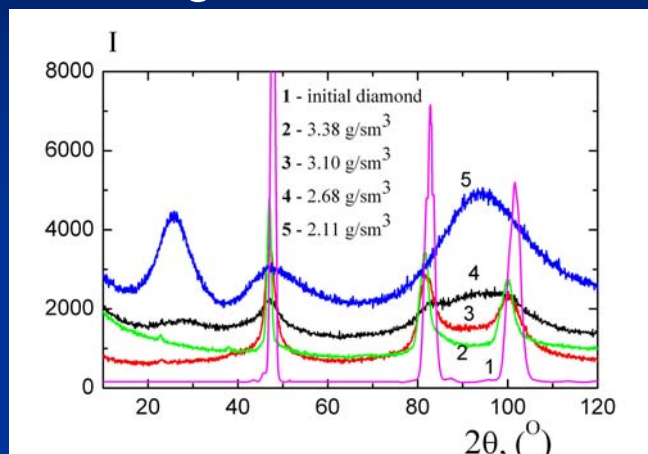
ball mill

Neutron diffraction  
Inelastic scattering of neutrons  
Small angle scattering  
Polarized neutrons

# Carbon nanoscale systems (diamond, fullerenes, graphite usw)

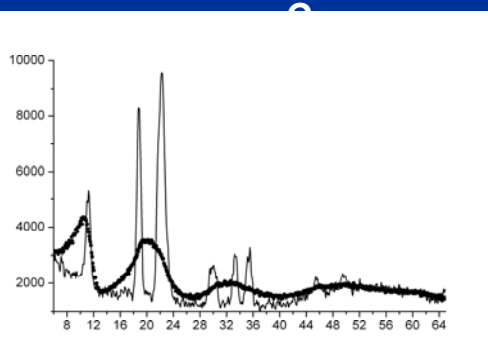
Short range in irradiated dimonds

Phase transition in nanoscale systems (polyamorphous transitions)

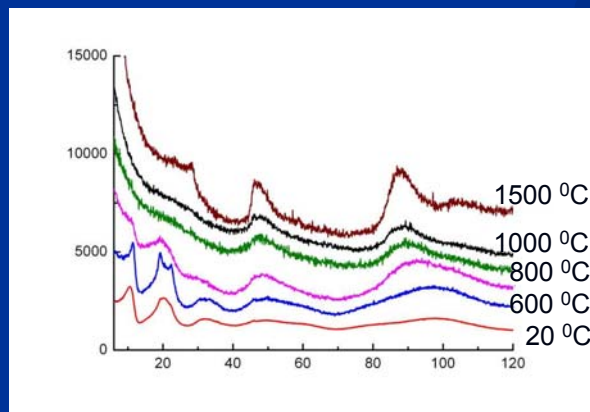


Transition from a diamond-like glass to a graphite-like glass upon change in density

Production of amorphous fullerenes (milling 50 hours)

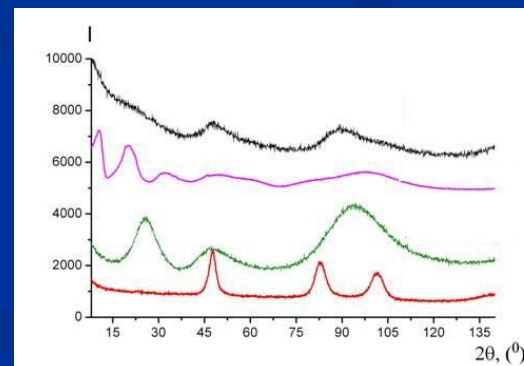


Annealing amorphous fullerenes



Termostability C<sub>60</sub>  
Cryst. 870 °C  
Amorph. 1700 °C

Transition in amorphous fullerenes from molecular in atomic glass



Atomic glass  
T=1300 K  
Molecular glass  
T=300 K  
Amorph. graphite  
T=300 K  
nanodiamond  
T=300 K

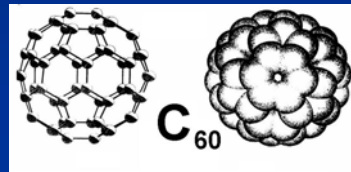


# Potential applications

Reactor materials  
Constructional materials

Alloy reactor materials with nanoscale  
fullerenes

High-temperature  
H-containing  
moderators

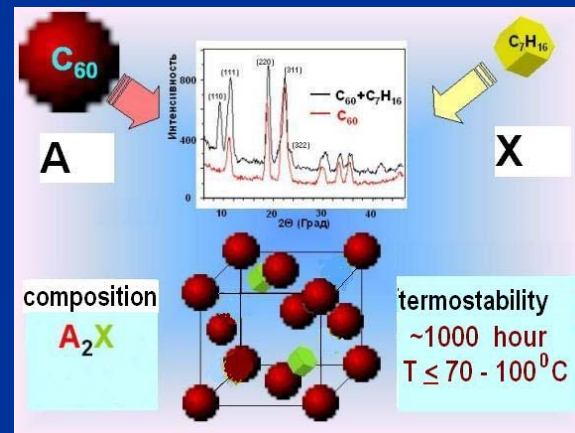


Metal glasses on a basis the elements  
used in reactor technology

Nanoscale metal hydrides

Nanoscale fullerene hydrides

Systems of the  
storage of  
combustible gases  
and fluids



Connections fullerenes with  
molecules of combustible gases  
and their derivatives

Sintering of  
detonation diamonds

Interaction nanoscale detonation  
diamond with amorphous fullerenes

# New Facilities: Scientific Technology Center of Nanotechnology

- More than 100 sets of unique and the most modern research, experimental, metrological and the process equipment
- Clean rooms

# The Structure of laboratories of Nanotechnology Centre

- Laboratory of structural researches and electronic microscopy of functional nanostructures and nanomaterials.
- Laboratory of physical and chemical properties of nanostructures and nanomaterials surface.
- Laboratory of physical properties of functional nanoelements and nanomaterials.
- Laboratory of development of methods of multilayered nanolithography.
- Laboratory of experimental methods of functional nanoelements, nanosensors and nanodevices production.
- Laboratory of radiobiology and biochips.
- Laboratory of Micro- and Nano- Electro Mechanics (including group of electroforming of metals).
- Laboratory of radiation material science and nanomaterials.
- Laboratory of theoretical researches of nanostructure physics (including group of nanosensor and functional nanoelements simulation).



# Examples of New Investigation Equipment

- Two 300-keV electron microscopes “Titan”
- Focused Ion Beam “Helios NanoLab™”
- Electron Lithography and other lithography systems
- Materials Deposition and Etching systems
- Ion Implantation system
- Biology and Medical Investigation system

# “Titan” Electron Microscope



Electron Microscope “Titan” provides the highest level of detail information available today—down to the sub-Ångström level, providing critical data for process development and materials research on a highly stable, easy-to-use platform. Titan is the next generation of a unique 300 kV range microscope for corrector and monochromator technologies.

# “Helios NanoLab” FIB system



The World's Most  
Advanced DualBeam™  
Solution for Superior  
Sample Preparation,  
Imaging and Analysis in  
the Lab.



# Electron Lithography system



The JBX-6300FS, equipped with a thermal field emission electron gun with a ZrO/W emitter, is an electron beam lithography system provided with the Vector Scan Method for beam deflection. The beam deflection employs 19bit DAC, and the accelerating voltage 25kV or 50kV or 100kV is selectable. The workpiece stage is driven by the step-and repeat-method, and up to 200 mm wafer can be loaded.

# Coating system



The TF600 coating system is designed for increased levels of process capability. Its unique configurations of external pump, remote equipment rack and larger chambers provide greater flexibility. Combined with flexible base and top plate arrangements and the ease of a touch screen control system, the TF600 delivers new standards in vacuum coating.

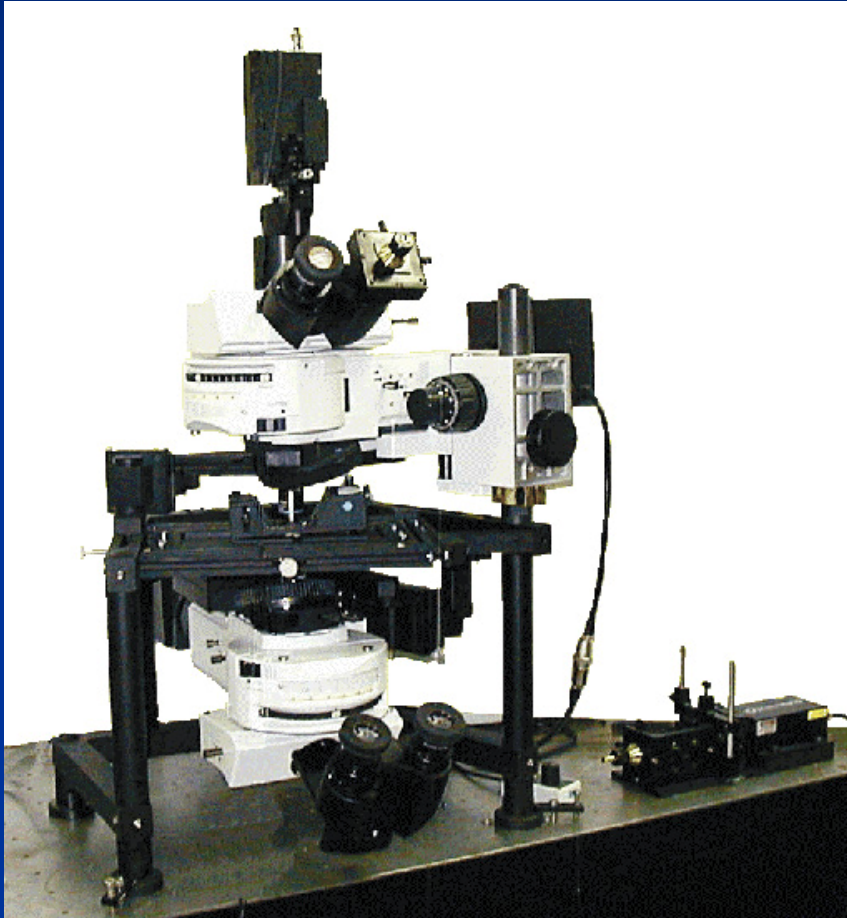
# Ion Implanter



The Optima HD is a high dose ion implanter that delivers precise and productive implants across a broad applications base, including source/drain, source/drain extension and poly-doping transistor forming applications. The Optima HD is also available with Hydrogen and molecular implant capabilities.



# AFM and NSOM system



## SPM modes:

- *AFM contact*
- *AFM Intermittent contact mode*
- *STM*
- *Electrical Measurements*

## Near Field Modes (NSOM):

- *Reflection*
- *Transmission*
- *Collection*
- *Fluorescence*
- *Photo-Luminescence*

## Far Field Methods:

- *Standard Microscope Imaging*
- *Fluorescence*
- *Confocal*

# Conclusions

Russian Research Center “Kurchatov Institute” is the most powerful scientific center in Russia in the Nanotechnology and Materials Science area. Great experience in the field of materials production and their property examination together with a modern equipment will provide a challenge of nanomaterials creation to build new nanoscale base devices.